

Optimized Fabrication and Application of Electrostatic Phase Plates for Transmission Electron Microscopy

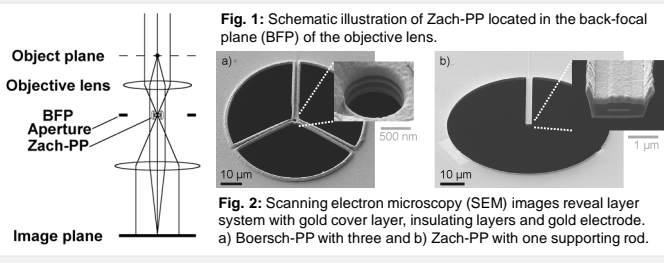
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Introduction

- Electrostatic physical phase plates (PP) enhance the contrast of weak-phase objects in transmission electron microscopy (TEM)
- An electrode, surrounded by insulating and metallic shielding layers, generates an electrostatic field close to the zero-order beam. (Fig.1) Depending on the applied voltage, a relative phase shift between scattered and unscattered electrons is induced.
- Boersch-PP**^[1]: Three supporting rods and an inner ring lens guarantee a homogeneous electrostatic field but obstruct information at low spatial frequencies (Fig. 2a). Cut-on frequency is determined by outer ring diameter.
- Zach-PP**^[2]: With only one supporting rod, obstruction of spatial frequencies is significantly reduced (Fig. 2b). Cut-on frequency is determined by the shape of the electrostatic field.



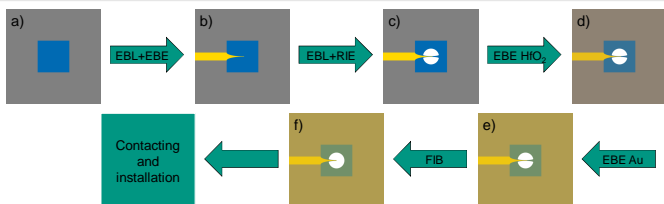
Motivation

- Electrostatic charging limits application of PPs
- Low spatial frequencies cannot be resolved with present PP design
 - ratio between size of diffraction pattern and PP dimension has to be enlarged by increasing the focal length and scaling down the PP sizes
 - need for small tip, large aperture radius and thin layers

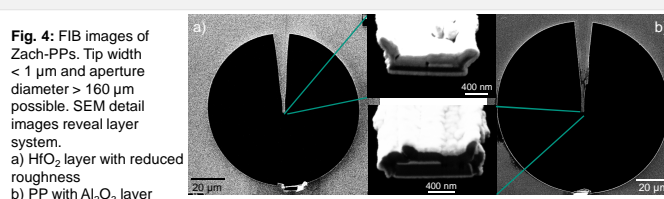
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Fabrication of Zach-PP

- Seven production steps to produce a Zach-PP (Fig. 3) including electron-beam evaporation (EBE), electron-beam lithography (EBL), focused ion beam (FIB) and reactive ion etching (RIE).



- RIE simplifies process and allows production of PPs with larger aperture radius and narrower tips due to high precision of EBL (Fig. 4).
- The high ϵ of HfO_2 guarantees good isolation in spite of thinner layers.

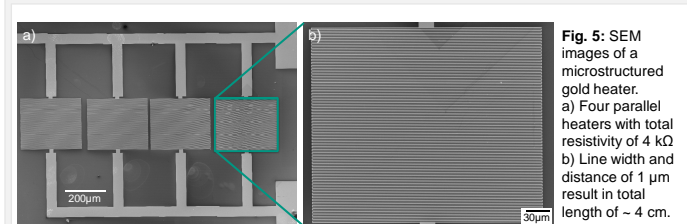


References

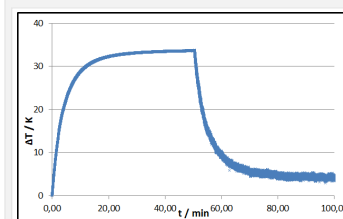
- [1] K. Schultheiß et al., Rev. Sci. Instrum. 77 (2006) 033701
- [2] K. Schultheiß et al., Microsc. Microanal. 16 (2010) 785-794

PP heating

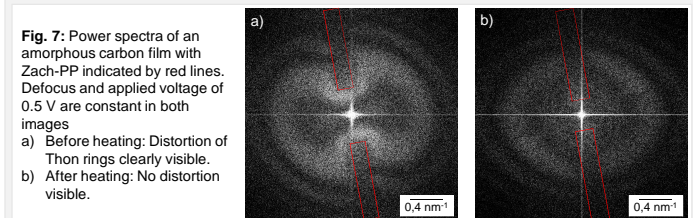
- To reduce contamination and thus electrostatic charging, PP is heated by a microstructured heater (Fig. 5)
- Fabricated with EBL and EBE
- Heating power of 90 mW at 30 V



- Application of a constant voltage \rightarrow resistivity and current drop with increasing temperature allowing temperature measurements (Fig. 6)
- Thermal stability is reached within one hour
- Temperatures $> 50^\circ\text{C}$ possible

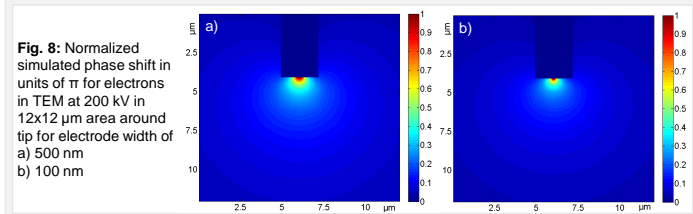


- Higher PP temperature reduces contamination and electrical charging visible in power spectra (Fig. 7)



Field simulations

- Simulations of electrostatic potential of Zach-PP provide better knowledge of phase-shifting characteristics (Fig. 8)



Summary

- Optimized fabrication with narrower PP design and enlarged aperture radius
- PP heating and thinner insulating layers significantly reduce electrostatic charging
- Potential simulations provide better knowledge of phase shift

Acknowledgement

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